## IN THE CLAIMS:

Please delete Claims 1-24, and 32-52 examined in the parent case.

Please amend the following claims:

- 25. A process for producing an elongated electrode for use in a laser comprising the steps of:
  - fabricating an elongated electrode structure comprised of one or more electrical conducting materials and having a long dimension of at least 50 centimeters and a width of at least 3 centimeters.
  - b) creating a porous insulating layer on a portion of said the elongated electrode, said the portion defining a discharge region having a width of at least 3 millimeters.
- 26. A process as in Claim 25 wherein said the one or more electrical conducting materials comprise a lead rich brass having a lead content of greater than 1 percent, and said the step of creating said the porous electrical insulating layer comprises operating said the electrode in a fluorine containing laser gas to permit a porous insulating layer to build up on the lead rich brass.
- 27. A process as in Claim 25 wherein said the step of creating said the porous insulating layer comprises spreading insulating particles on the discharge region of said the elongated electrode structure.
- 28. A process as in Claim 25 wherein said step of creating said the porous insulating layer comprises the steps of:
  - mixing insulating particles in a molten metal to produce a discharge section of said the elongated electrode said the section comprising a filler metal and said the insulating particles,
  - b) operating said the elongated electrode in a fluorine containing laser gas environment to permit a portion of said the filler metal to sputter away leaving a porous insulating layer covering said the discharge region.

- 29. A process as in Claim 28 wherein said the insulating particles have dimensions in the range of about 50 to 150 microns.
- 30. A process as in Claim 28 wherein said the particles have dimensions in the range of about 50 to 150 microns.
  - 31. A process as in Claim 25 wherein said the step of creation of porous insulating layer includes the substeps of creating:
    - a. creating a plurality of nucleation sites on said the discharge surface;
    - b. operating said the electrode in a laser containing fluorine gas so as to permit said the porous insulating layer to grow on said the discharge surface.